CITY OF MOUNTAIN VI

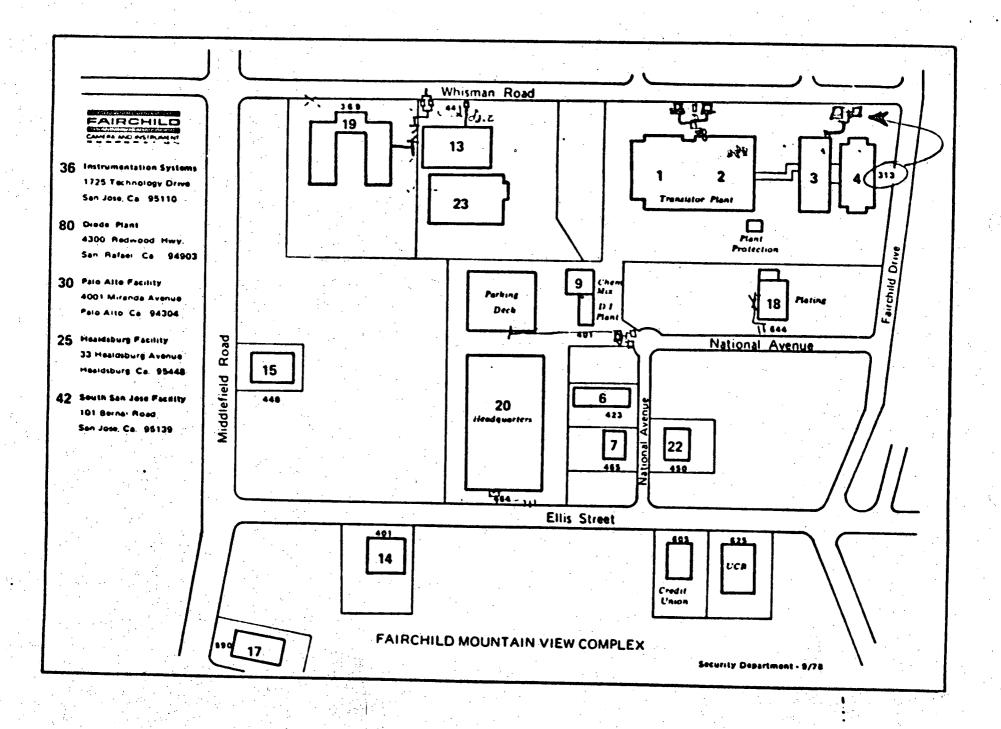
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SFUND RECORDS CTR 2807-91364

APPLICATION FOR INDUSTRIAL WASTES DISCHARGE PERMIT

ate September 9, 1	983			No.	and the same of th
. Name or Organization	Fairchild	-Linear Divisi	on Build	MG #1-4	
Address 313 Fairc	hild Drive	, Mountain Vie	w, Ca. 94039		(415)
Address of Point of D	Discharge 54	5 Whisman Rd.	Mtn. View. C	a. 94039	962-4226
Individual Responsit	ole Name Ge	orge J. Lechne	<u>r_,</u>		Telephone
for Industrial Wast	e Signature	* Storget Le	chron		
Attach Map Showing Po	oint of Disch	arge, Sampling Poi	rts, and Waste 1	reatment Fac	11169
	O300,0009a	ls/day Max. 4 <u>00</u>	.000 gals/day	Peak Hour	Ly 400 GPM
Submit separate state	ement:	-			
2. Listing chemicals 3. Describing waste 4. Giving characters 5. Concerning radios	used and appointment fac- stics of exceptive wastes	d nature of productoroximate concentrations industrial arged and concentrations.	ations 1 wastes	of discharge	
indicate the point of rates where applicable	discharge co	oncentration of the	e following char	racteristics	and mass emission
Biochemical oxygen de	emand (B.O.D.)	10 mg/1	Grease and o	l total	0 mg/1
Chemical oxygen demand (C.O.D.)					5.5 - 10.0
Total Solids, Average		100			5.0 mg/1
Suspended Solids, Ave		10 mg/1	Temperature		60° _F
	Max. Conc. Allowable mg/l	Allowable Mass Emission Rate kg/day		Max. Conc. Allowable mg/l	Allowable Mass Emission Rate kg/day
Arsenic	0.1	0.01	Cyanides	1.0_	0.1
Barium	5.0	0.5	Formaldehyde	5.0	0.5
Beryllium	1.0	0.1	Lead	0.5	0.05
Boron	1.0	0.1	Manganese	1.0	_0.1
Cadmium	0.1	0.01	Mercury	0.05	0.005
hromium Hexavalent	1.0	0.1	Nickel	1.0	0.1
Chromium Total	2.0	0.2	Phenols	1.0	0.1
Cobalt	1.0	0.1	Selenium	2.0	0.2
Copper	1.0	0.1	Silver	5.0	0.5
Cresols	2.0	0.2	Zinc	5.0	0.5
	NO.	OT TO BE COMPLETED	BY APPLICANT		
	The second secon	ge Industrial Wast	es in Accordance	with This	
Permi Applic	t to Dischard ation Subject	to Attached Gene	ral and Specific	c Conditions	
Permi Applic Maintenance Director	t to Dischard	to Attached Gene	ral and Specific	Conditions Date	

Maintenance Director



ADDENDUM

APPLICATION FOR INDUSTRIAL WASTES DISCHARGE PERMIT

1. Type of Industry and Nature of Products

Fairchild, Linear Division, processes silicon into electronic semiconductor devices, such as circuits for amplifiers, television, audio, telecommunications and voltage regulators.

2. Chemicals used in semiconductor device processing

lauids Liquids Acetic acid Gases Aluminum sulfate solution Ammonia Detergents Acetone Argon Freon Ammonium fluoride Arsine G1vcerin Ammonium hydroxide Boron Trichloride Isopropanol Hydrochloric acid Chlorine Methanol Hydrofluoric acid Compressed air Methylene chloride Nitric acid Diborane Sodium carbonate solution Phosphoric acid Hydrogen Sodium hydroxide solution Phoshorous oxychloride Hydrogen chloride Trichloroethane Sulfuric actd Nitrogen. Xylene | 0xygen

3. Waste Treatment Facilities

Neutralization of acids is provided by injection of NaOH and/or H₂SO₄ (or HCl) into mixing tanks with continuous monitoring and control. Fluoride solutions are captured and disposed of separately, not into the city sewer.

- 4. Characteristics of exceptional industrial wastes None.
- 5. Radioactive Wastes

Phosphine:

No radioactive wastes are discharged.

6. Organic Solvents

Organic solvent wastes are drummed for subsequent recycling/or disposal at approved recycling, treatment or disposal facilities.

